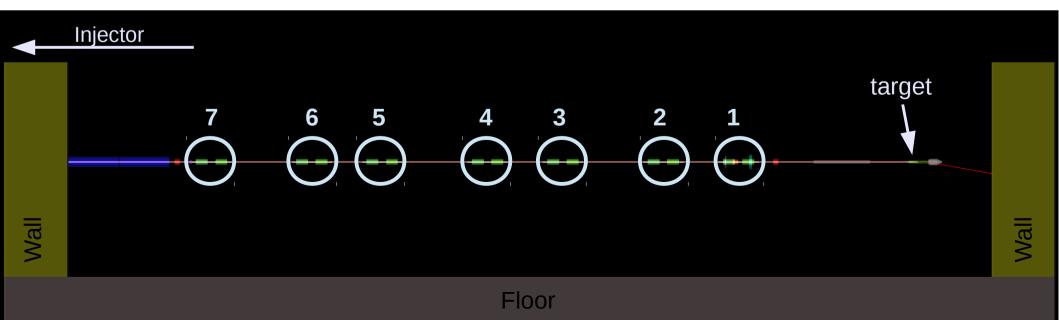


Raster Position and Power (for eHD in UITF)



Method

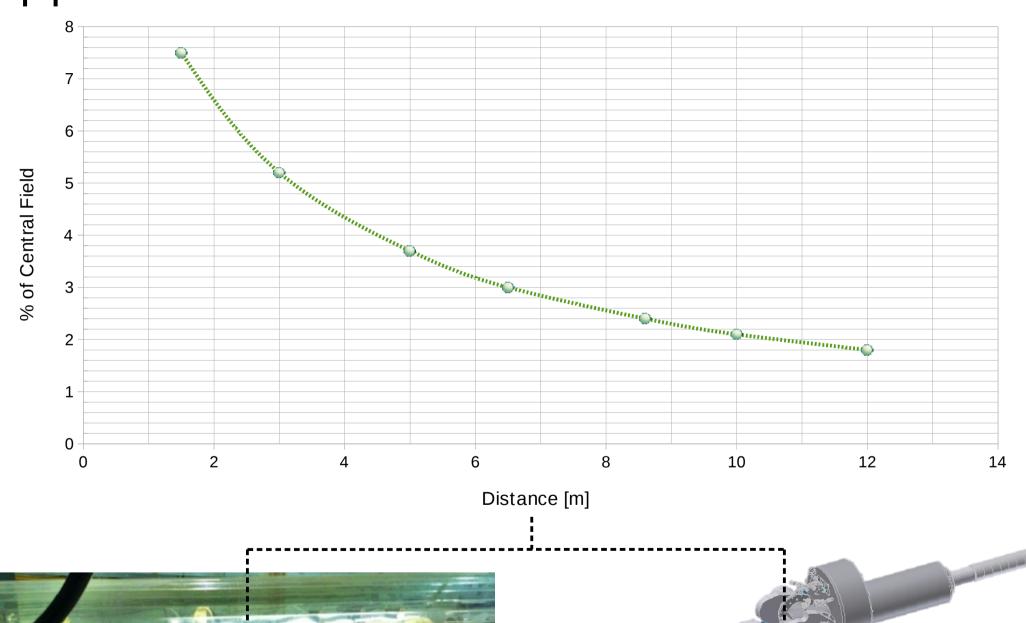
- Seven Raster positions along the beamline were used.
- For each position, the maximum Raster power (expressed as a percentage of the 6-GeV central field value, 51.2 G) was determined with the requirement that the electron makes it to the HDice target.



Assumptions

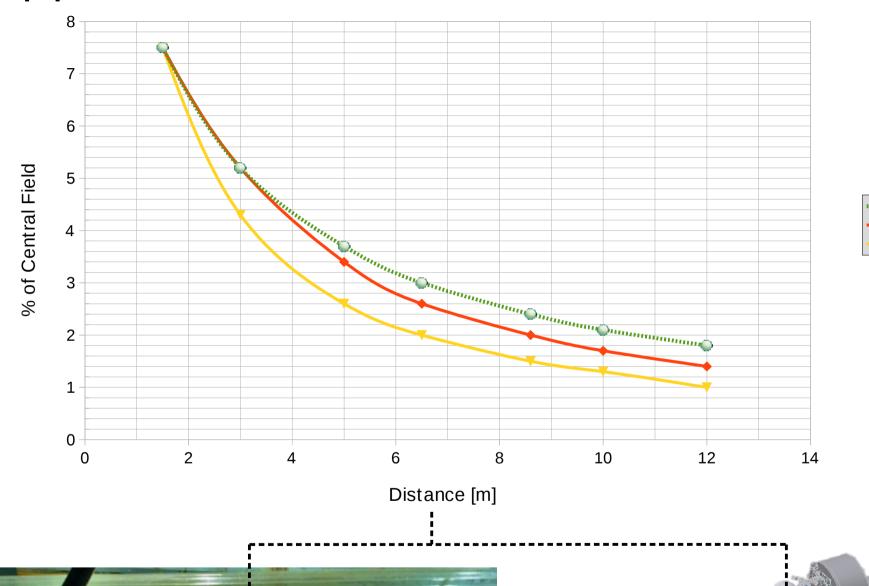
- All beamline components have an ID of 2 inches (?)
- The beamline itself has an ID of 1.5 inches (?)
- Raster beam pipe has an ID of 0.75 inches (?)
- Raster aperture is 2 inches (?)
- E_{beam} = 10 MeV
- $\sigma_{x} = 100 \ \mu m$
- $\sigma_{y} = 100 \ \mu m$

% of Central Field v. Distance [m]





% of Central Field v. Distance [m]



1.5" ID beamline
1.0" ID beamline
0.75" ID beamline

